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Docket No.: 543822005300
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Steven WANG et al.

Application No.: 10/812,412

Confirmation No.: 1275

Filed: March 30, 2004

Art Unit: 2814

For: METHOD FOR PRODUCING A DEEP
TRENCH CAPACITOR IN A
SEMICONDUCTOR SUBSTRATE

Examiner: N. W. Ha

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

This is in response to the non-final Office Action dated July 26, 2005, for which a response is due on October 26, 2005. Accordingly, this response is timely filed. Reconsideration and allowance of the pending claims, as amended, in light of the remarks presented herein are respectfully requested.

Amendments to the Specification begin on page 3 of this paper.

Amendments to the Abstract begin on page 4 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 5 of this paper.

Remarks begin on page 7 of this paper.